

Supplementary Information

A Tri-Functional Molecular Relay to Fabricate a Size-controlled CoO_x Nanoparticles & WO₃ Photoanode for Efficient Photoelectrochemical Water Oxidation

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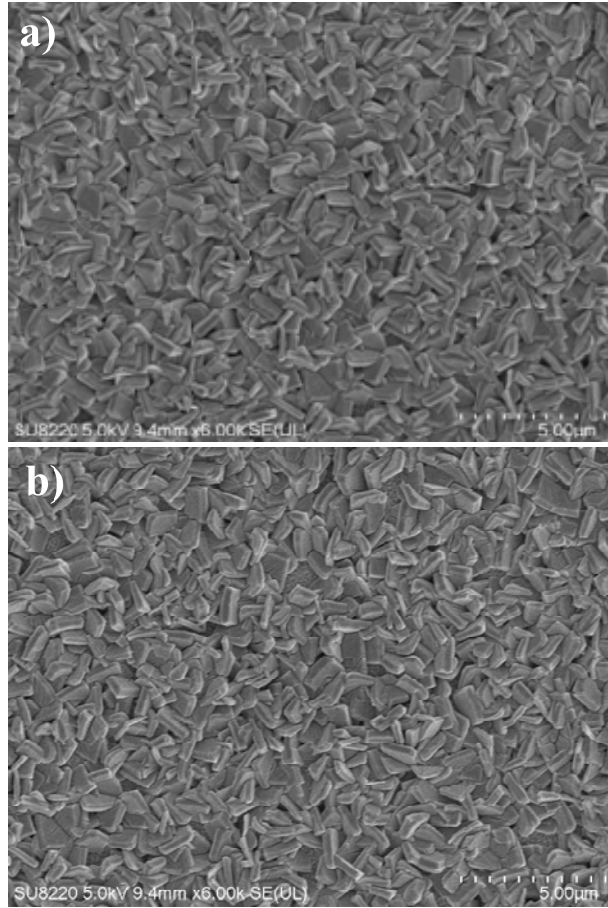


Figure S1. SEM of the bare WO_3 and $\text{C-M2P-CoO}_x/\text{WO}_3$ electrode.

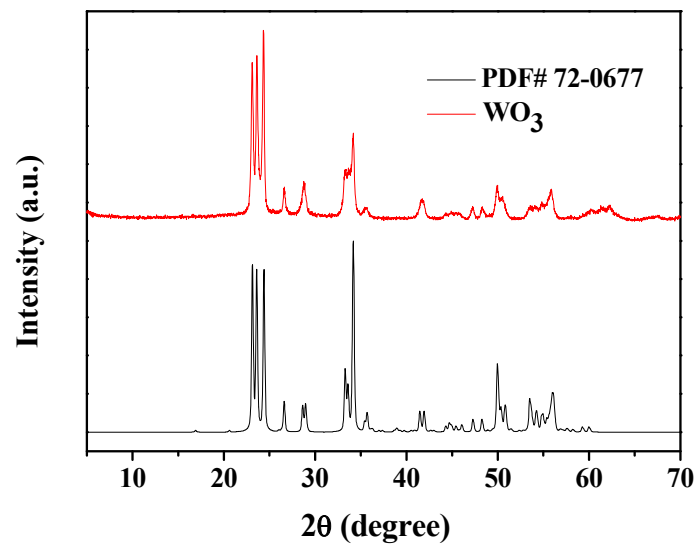


Figure S2. XRD of the bare WO₃.

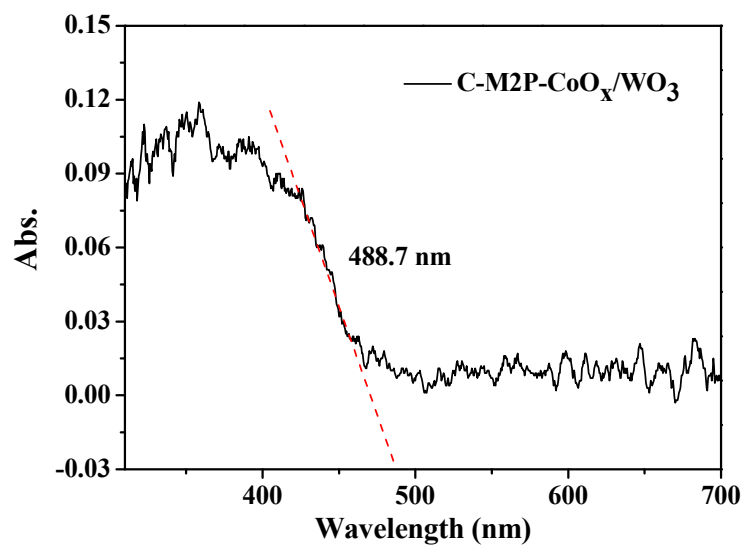
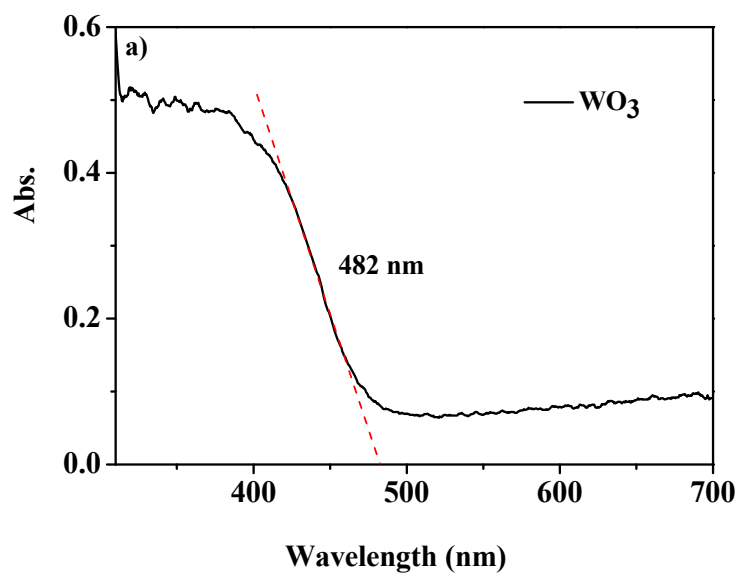


Figure S3. the UV-vis DRS of (a) WO_3 and (b) $\text{C-M2P-CoO}_x/\text{WO}_3$ films.

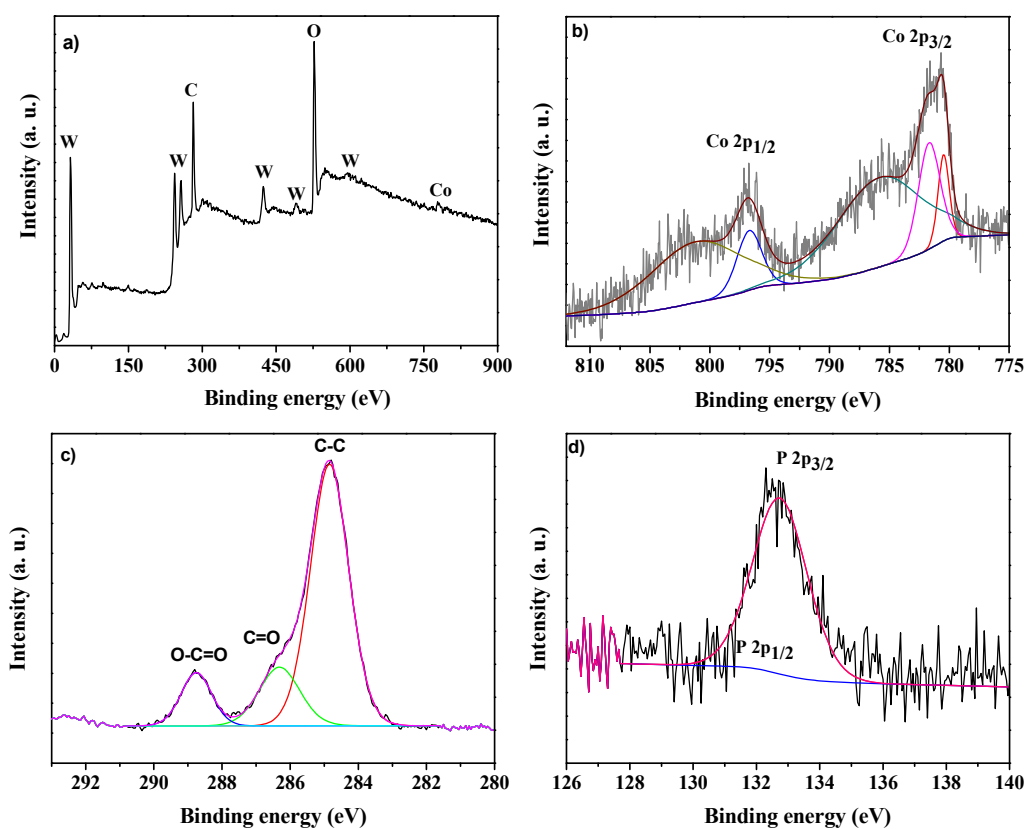


Figure S4. a) the XPS full scan and fine scan of b) Co, c) C and d) P on C-M2P-CoO_x/WO₃ films after 2 h photoelectrolysis.

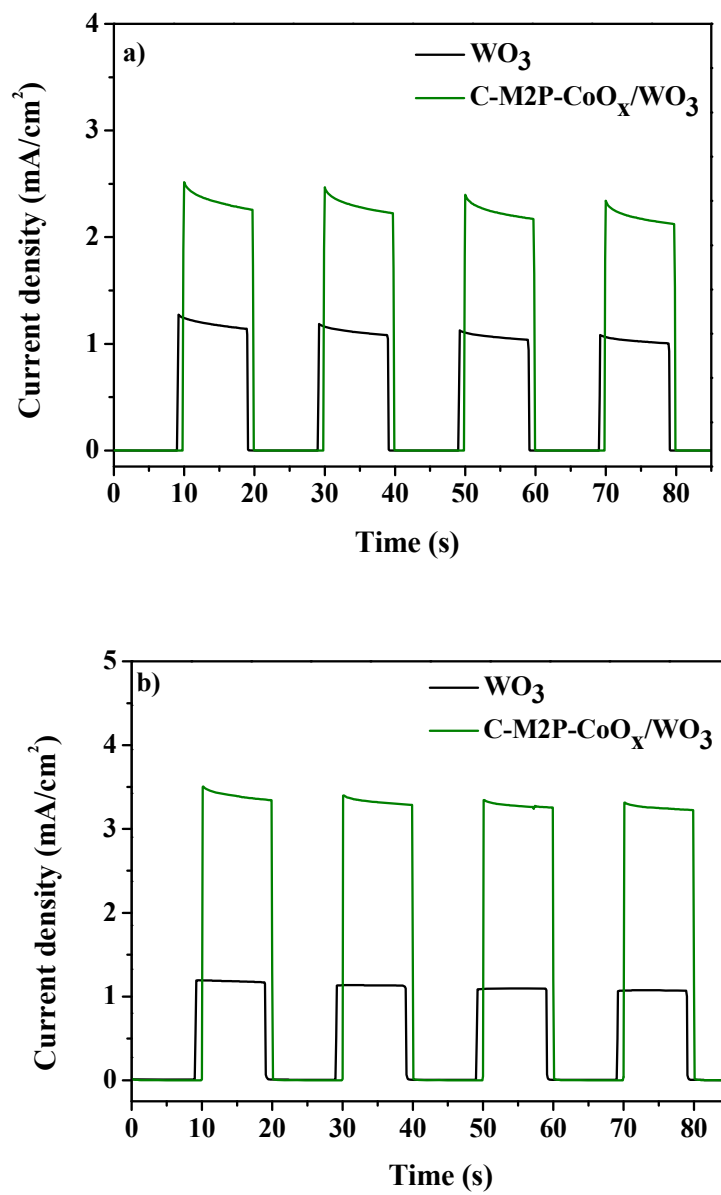
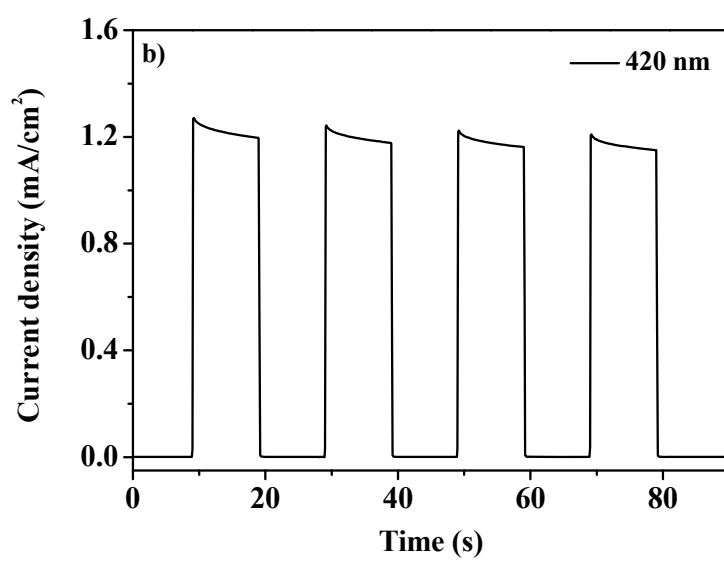
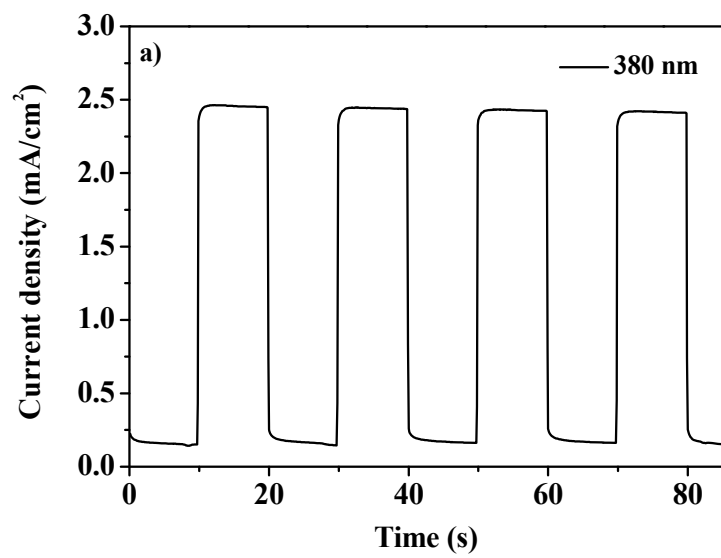


Figure S5. the photoelectrochemical behavior based on $\text{C-M2P-CoO}_x/\text{WO}_3$ electrode when applied different external bias at (a) 0.75 V and (b) 1.23 V under illumination by LEDs ($\lambda = 400$ nm).



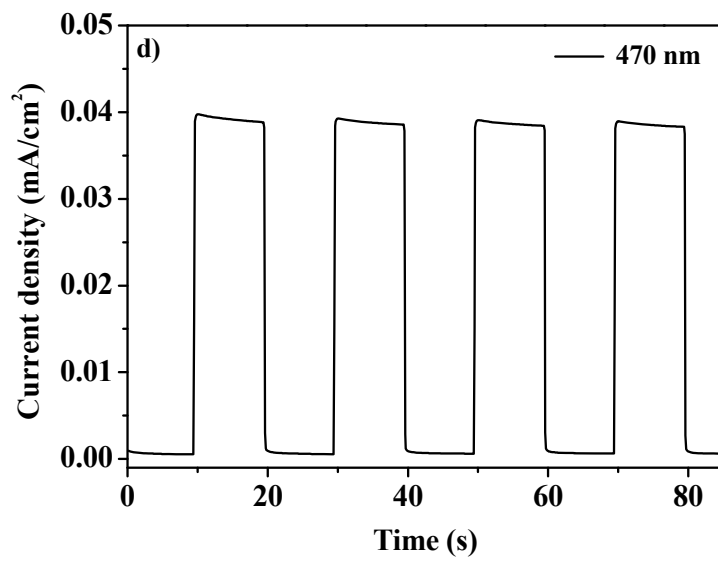
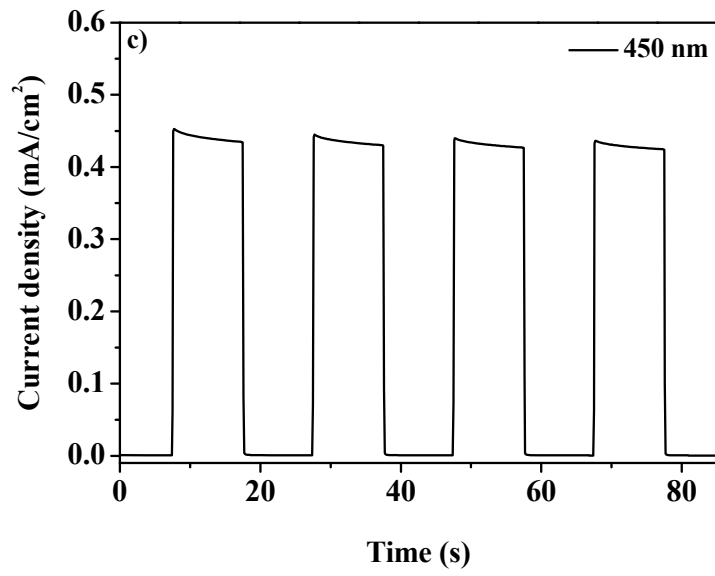


Figure S6. photocurrent densities based on C-M2P-CoO_x/WO₃ electrode under illumination by LEDs with λ (a) at 380 nm, (b) at 420 nm, (c) at 450 nm and (d) at 470 nm when applied 0.75 V external bias.

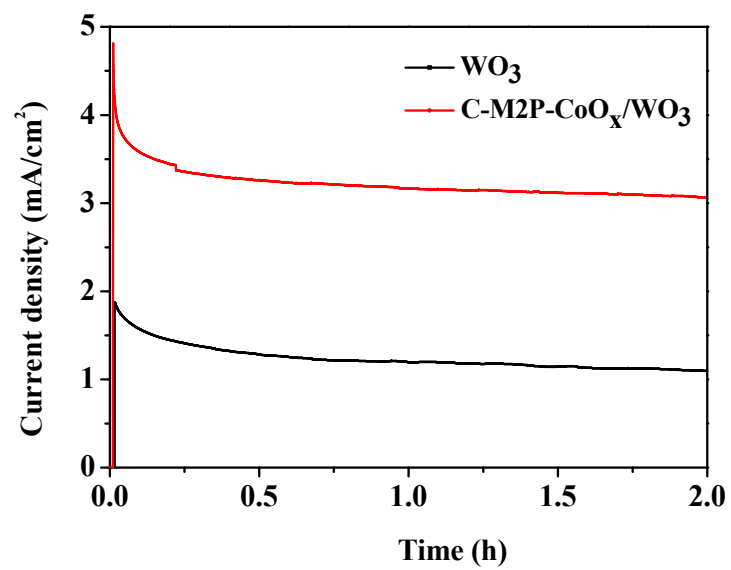


Figure S7. The controlled-potential electrolysis of water oxidation based on C-M2P-CoO_x/WO₃ electrode at 1.23 V under continued visible-light irradiation ($\lambda = 400$ nm).

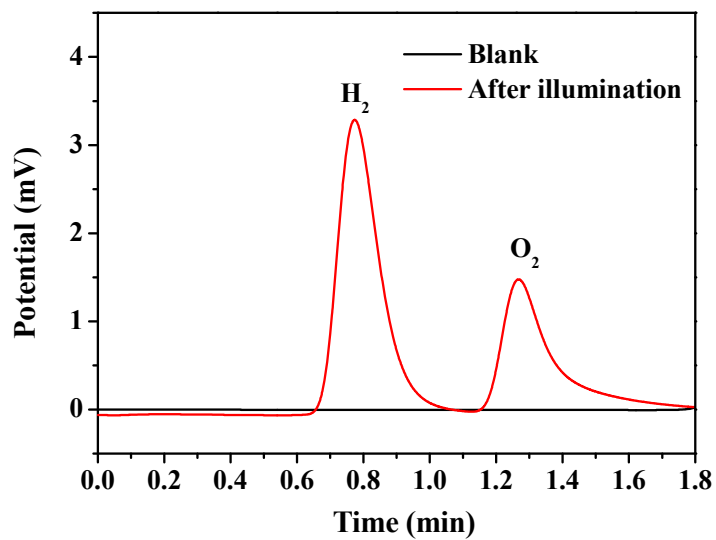


Figure S8. The detection of hydrogen and oxygen by GC based on C-M2P-CoO_x/WO₃ electrode after photoelectrolysis at 0.75 V under continued visible-light irradiation ($\lambda = 400$ nm). finite.

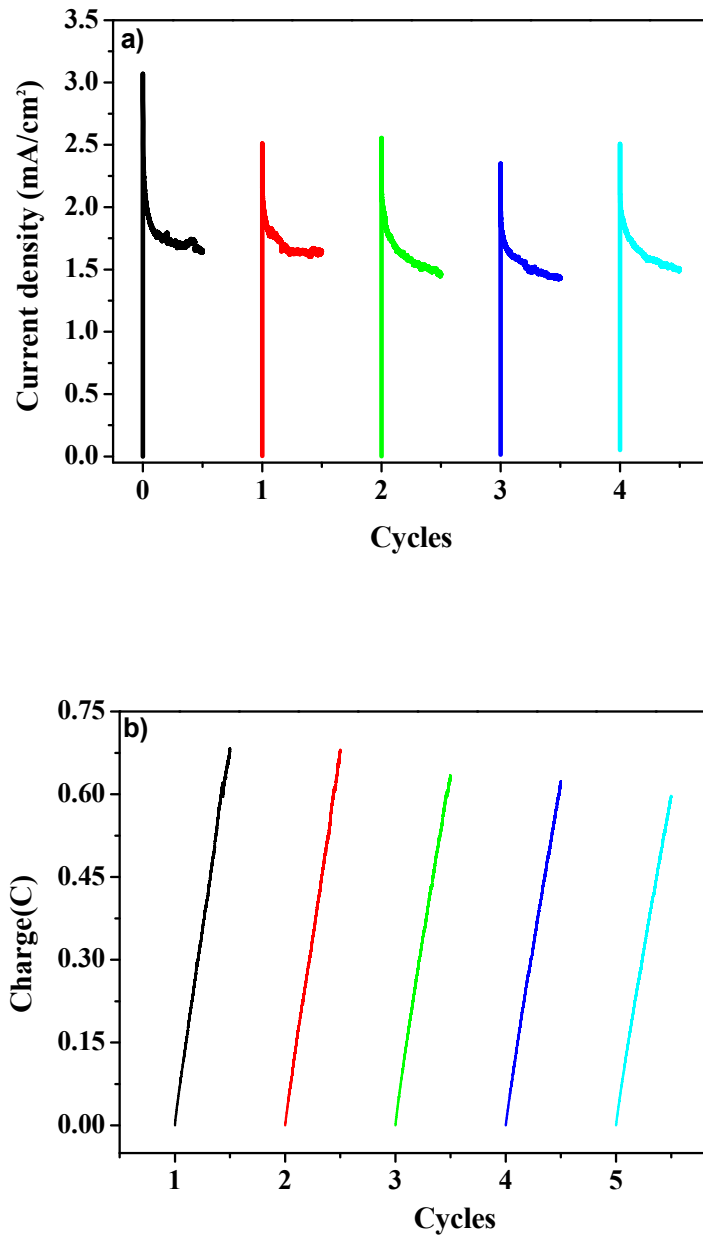


Figure S9. a) C-M2P-CoO_x/WO₃ electrode reused for bulk photoelectrolysis and performed for five cycles with 0.75V bias; b) the produced charge under continued visible-light irradiation ($\lambda = 400$ nm).

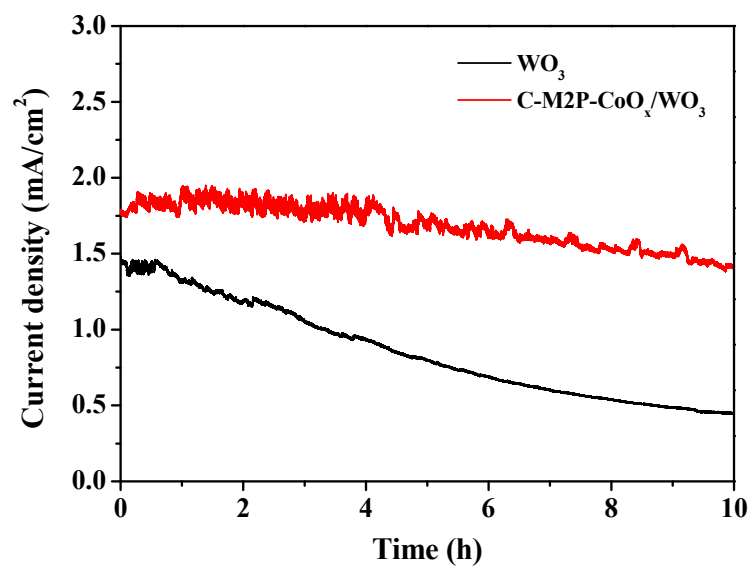


Figure S10. Controlled-potential electrolysis of water oxidation based on WO₃ and C-M2P-CoO_x/WO₃ for 10 h under continued visible-light irradiation ($\lambda = 400$ nm) with the bias at 0.75 V.

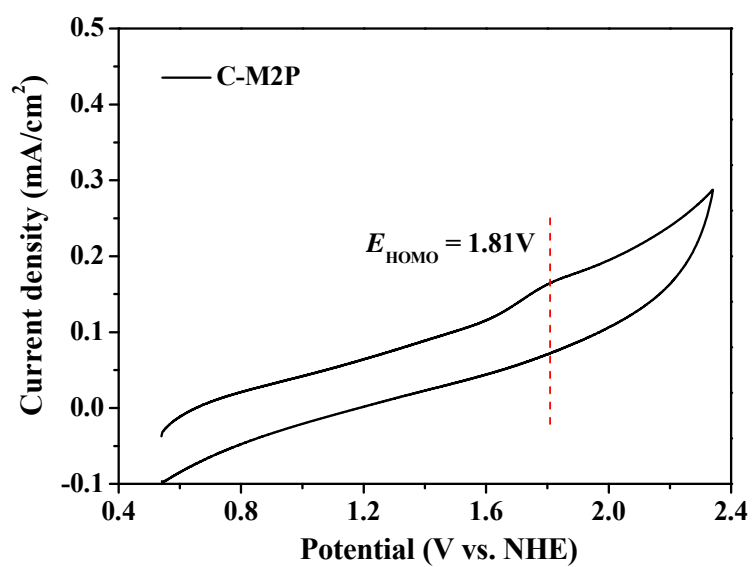


Figure S11. HOMO level measured based on CV of C-M2P vs. NHE. ^[1]

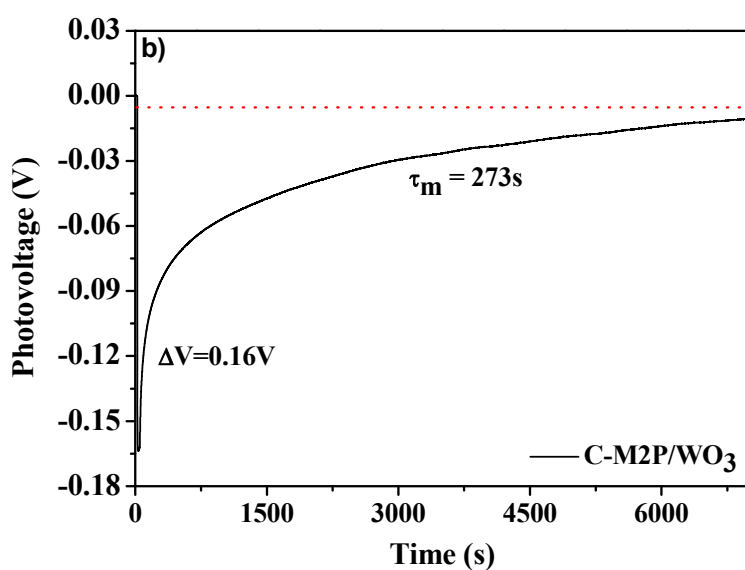
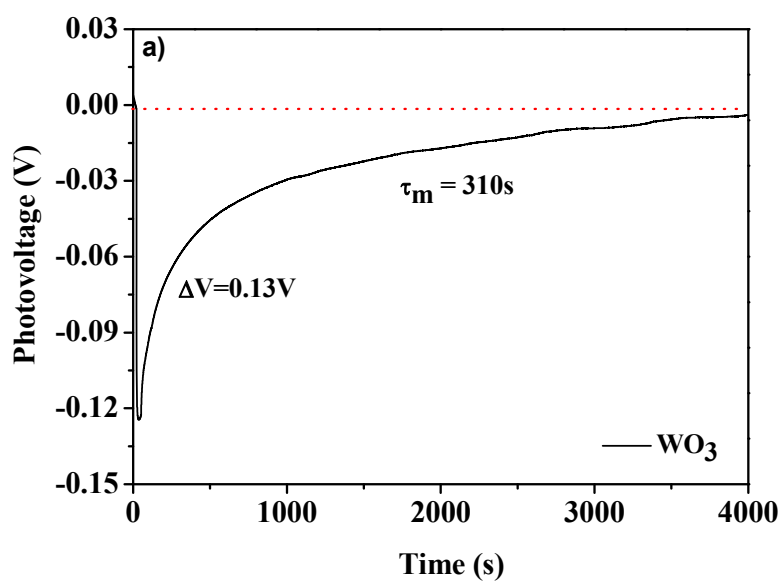


Figure S12. OCVD plots of (a) WO_3 , (b) C-M2P/ WO_3 photoanode with 400 nm LED lamp illumination from the electrolyte-electrode side (ΔV is the difference in voltage between dark and illumination conditions, τ_m is the decay lifetime).

It is noted that the measurement here operated for the complete charge decay of the WO_3 , and C-M2P/ WO_3 photoelectrode. The differences in ΔV compared with Fig. 7 might be originated from the experimental error. However, the decay trend among WO_3 , C-M2P/ WO_3 and C-M2P- CoO_x / WO_3 is clearly sustained.

The calculation for E_{CB} and E_{VB} for WO_3 film.

In general, a simple method can be applied to determine the band edge positions of CB and VB of a semiconductor respectively. The CB edge of a semiconductor at zero charge (pH_{zpc}) can be figured up using the following equation S1-2. [2]

$$E_{CB} = \chi - E^e - 1/2 E_g \quad (1)$$

$$E_{VB} = E_g + E_{CB} \quad (2)$$

where E_{CB} is the CB edge potential, E_{VB} is the VB edge potential, and χ is the electronegativity of the semiconductor, expressed as the geometric mean of the absolute electronegativity of the constituent atoms, which is defined as the arithmetic mean of the atomic electron affinity and the first ionization energy. E^e is the energy of free electrons on the hydrogen scale, about equal to 4.5 eV.

The calculation for carrier densities N_d of C-M2P-CoO_x/WO₃ electrode.

The carrier densities of the prepared C-M2P-CoO_x/WO₃ electrode could be estimated using the Mott-Schottky equation. [3]

$$1/C^2 = (2/e_0\epsilon\epsilon_0N_d)[(V - V_{FB}) - kT/e_0] \quad (3)$$

Where C is the specific capacitance (F cm⁻²), e_0 is the electron charge, ϵ is the dielectric constant of WO₃ ($\epsilon = 20$), ϵ_0 represents the permittivity of vacuum, N_d is the carrier density, V is the electrode applied potential, V_{FB} is the flatband potential and kT/e_0 is a temperature-dependent correction term.

ABPE measurement ^[4]

The applied bias photon-to-current efficiency (ABPE) was calculated from the LSV using the equation:

$$\text{ABPE}(\%) = \frac{(J_{\text{light}} - J_{\text{dark}}) \times (1.23 - V_{\text{RHE}})}{P_{\text{light}}} \times 100\% \quad (4)$$

Where V_{RHE} is the applied potential versus RHE, J_{light} and J_{dark} are the measured photocurrent and dark current respectively, and P_{light} (mW cm^{-2}) represents the power density.

IPCE measurement ^[5]

IPCE measurement was carried out in a three-electrode setup with the assembled- electrode as the working electrode, platinum disk as counter electrode, and Ag/AgCl (3.0 M KCl) as reference electrode. IPCE was calculated according to equation:

$$\text{IPCE}(\%) = \frac{1240 \times J}{\lambda \times I} \times 100\% \quad (5)$$

Where, J represents the photocurrent density (mA cm^{-2}), λ is the wavelength of incident light (nm), and I is the intensity of the incident light (mW cm^{-2}).

The calculation for the lifetime τ_m based on Open circuit voltage decay (OCVD) plots.^[6]

The calculated decay lifetime of each V-t profiles by fitting to a biexponential function with two time constants:

$$y(t) = A_0 + A_1 e^{-t/\tau_1} + A_2 e^{-t/\tau_2} \quad (6)$$

$$\tau_m = (\tau_1 \tau_2) / (\tau_1 + \tau_2) \quad (7)$$

where τ_m is the harmonic mean of the lifetime and the total half life is $\log(2 \times \tau_m)$.

Supporting References

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End of Supporting Information